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ON THE COVER: Photographs depicting materials science and engineering education in action surround the tetrahedron which is becoming a symbol for materials science and engineering.

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The Materials Research Society (MRS) is a nonprofit scientific association founded in 1973 to promote interdisciplinary goal-oriented basic research on materials of technological importance. Membership in the Society includes more than 4,800 scientists from industrial, government, and university research laboratories in the United States and more than 25 countries.

The Society's interdisciplinary approach to the exchange of technical information is qualitatively different from that provided by single-disciplinary professional societies because it promotes technical exchange across the various fields of science affecting materials development. MRS sponsors two major international annual meetings encompassing approximately 30 topical symposia, as well as numerous single-topic scientific meetings each year. It recognizes professional and

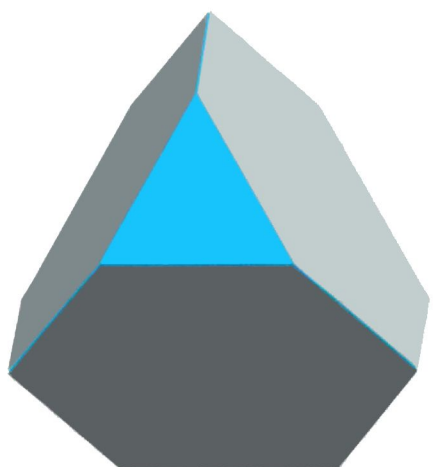
technical excellence, conducts short courses, and fosters technical exchange in various local geographical regions through Section activities and Student Chapters on university campuses.

MRS is an Affiliated Society of the American Institute of Physics and participates in the international arena of materials research through associations with professional organizations such as European MRS.

MRS publishes symposia proceedings, the *MRS BULLETIN*, *Journal of Materials Research*, and other volumes on current scientific developments.

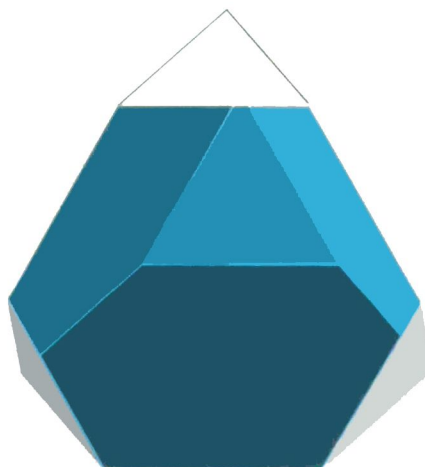
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germoxanes	N.D. [5]
chlorogermanes	N.D. [5]
N_2	2
THC	1
H_2O	1
O_2	1
CO	1
CO_2	2



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Si_3H_8	N.D. [1]
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siloxanes	2
chlorosilanes	none
N_2	2
THC	1
H_2O	1
O_2	1
CO	1
CO_2	1

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